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## IN THE CLAIMS:

Please amend claims 6, 12, 18, 24 and 30 as follows:

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6. (Amended) The device of claim 1 wherein said display is a digital gradation display.

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12. (Amended) The device of claim 7 wherein said display is a digital gradation display.

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18. (Amended) The device of claim 13 wherein said display is a digital gradation display.

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24. (Amended) The device of claim 19 wherein said display is a digital gradation display.

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30. Amended) The device of claim 25 wherein said display is a digital gradation display.

Please add new claims 31-55 as follows:

Supp'

- --31. The device of claim 1 wherein said display further comprises a tuner for receiving television radio wave to constitute a television.
- 32. The device of claim 7 wherein said display further comprises a tuner for receiving television radio wave to constitute a television.

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33. The device of claim 13 wherein said display further comprises a tuner for receiving television radio wave to constitute a television.

34. The device of claim 19 wherein said display further comprises a tuner for receiving television radio wave to constitute a television.

35. The device of claim 25 wherein said display further comprises a tuner for receiving television radio wave to constitute a television.

36. The device of claim 31/wherein said television is a liquid crystal television.

37. The device of claim 32 wherein said television is a liquid crystal television.

38. The device of claim 33 wherein said television is a liquid crystal television.

39. The device of claim 34 wherein said television is a liquid crystal television.

40. The device of claim 35 wherein said television is a liquid crystal television.

41. The device of claim 1 wherein said thin film transistor has at least one gate electrode adjacent to said semiconductor film, said gate electrode comprising

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a material selected from the group consisting of silicon, molybdenum, tungsten, molybdenum silicide, and tungsten silicide.

42. The device of claim 7 wherein said thin film transistor has at least one gate electrode adjacent to said semiconductor film, said gate electrode comprising a material selected from the group consisting of silicon, molybdenum, tungsten, molybdenum silicide, and tungsten silicide.

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- 43. The device of claim 13 wherein said thin film transistor has at least one gate electrode adjacent to said semiconductor film, said gate electrode comprising a material selected from the group consisting of silicon, molybdenum, tungsten, molybdenum silicide, and tungsten silicide.
- 44. The device of claim 19 wherein said thin film transistor has at least one gate electrode adjacent to said semiconductor film, said gate electrode comprising a material selected from the group consisting of silicon, molybdenum, tungsten, molybdenum silicide, and tungsten silicide.
- 45. The device of claim 25 wherein said thin film transistor has at least one gate electrode adjacent to said semiconductor film, said gate electrode comprising a material selected from the group consisting of silicon, molybdenum, tungsten, molybdenum silicide, and tungsten silicide.
- 46. The device of claim 1 wherein a liquid crystal material is formed between said substrate and an opposite substrate, said liquid crystal material selected from the group consisting of a twisted nematic liquid crystal, super twisted

nematic liquid crystal, ferroelectric liquid crystal, antiferroelectric liquid crystal, dispersion liquid crystal, and polymer liquid crystal.

- 47. The device of claim 7 wherein a liquid crystal material is formed between said substrate and an opposite substrate, said liquid crystal material selected from the group consisting of a twisted nematic liquid crystal, super twisted nematic liquid crystal, ferroelectric liquid crystal, antiferroelectric liquid crystal, dispersion liquid crystal, and polymer liquid crystal.
- 48. The device of claim 13 wherein a liquid crystal material is formed between said substrate and an opposite substrate, said liquid crystal material selected from the group consisting of a twisted nematic liquid crystal, super twisted nematic liquid crystal, ferroelectric liquid crystal, antiferroelectric liquid crystal, dispersion liquid crystal, and polymer liquid crystal.
- 49. The device of claim 19 wherein a liquid crystal material is formed between said substrate and an opposite substrate, said liquid crystal material selected from the group consisting of a twisted nematic liquid crystal, super twisted nematic liquid crystal, ferroelectric liquid crystal, antiferroelectric liquid crystal, dispersion liquid crystal, and polymer liquid crystal.
- 50. The device of claim 25 wherein a liquid crystal material is formed between said substrate and an opposite substrate, said liquid crystal material selected from the group consisting of a twisted nematic liquid crystal, super twisted nematic liquid crystal, ferroelectric liquid crystal, antiferroelectric liquid crystal, dispersion/liquid crystal, and polymer liquid crystal.